What's Next?

Contrast and Image Formation

- Electron Scattering

On the horizon...

Feb 3: Alignment and Performance of the TEM (J. Turek)

- Optimizing the resolving power of the TEM

Feb 5: TEM Demo (D. Sherman/M. Sherman)

- The TEM up close and personal

Feb 10: Operation of the TEM (J. Turek)

- The ABCs of TEM operation

KEY CONCEPTS:

- Specimens are made of atoms
- Electron beam interacts with (*i.e.* scatters from) specimen atoms
- Image contrast arises both from electron scattering and interference (phase) effects

MORE KEY CONCEPTS:

- Resolution in electron images of biological specimens (and virtually any <u>thin</u> specimen) is normally limited by contrast NOT lack of resolving power
- Resolving power of TEM: 0.2 0.3 nm (2 3Å)
- Resolution in TEM images: *generally* 1-5 nm for most biological specimens

IMAGE CONTRAST:

- Determined by nature and extent of interactions between electron beam and specimen
- Properties of specimen (inherent contrast) AND microscope (instrumental contrast) are both important

DEFINITION: CONTRAST

The **relative** difference in intensity between an image point and its surroundings

Percent contrast =
$$100 \times \frac{|I_i - I_b|}{I_b}$$

 I_i = intensity of an image point

 I_{b} = intensity of the background **adjacent** to the image point

Contrast in LM vs. TEM

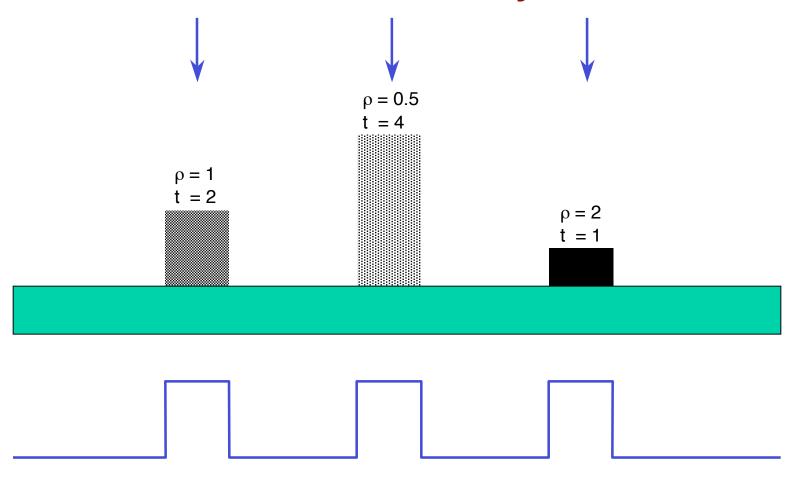
- LM differential absorption of photons
 - depends mainly on staining
- **EM** differential **scattering** of electrons
 - negligible absorption of electrons for "thin" specimens (*i.e.* <100-200 nm)

I.C.1 Electron Scattering

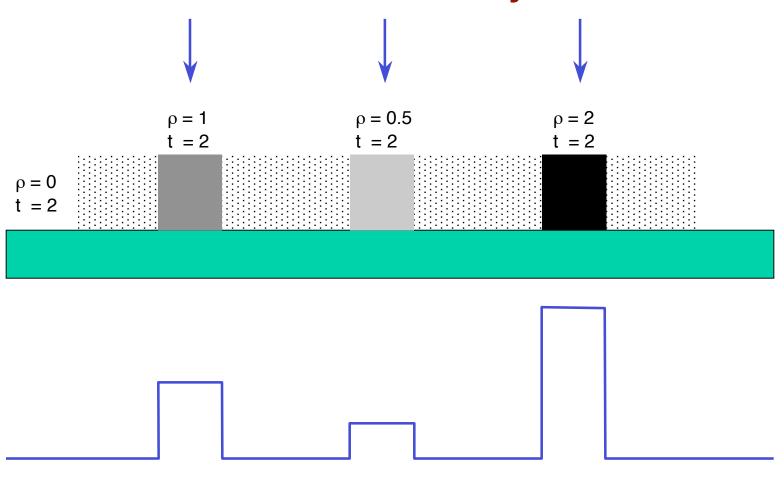
Some facts:

- Amount of scattering at any particular specimen point depends on its density and overall thickness
- Scattering is *relatively* **independent** of atomic number, chemical composition, or other specimen properties
- Probability of scattering increases with increasing mass thickness

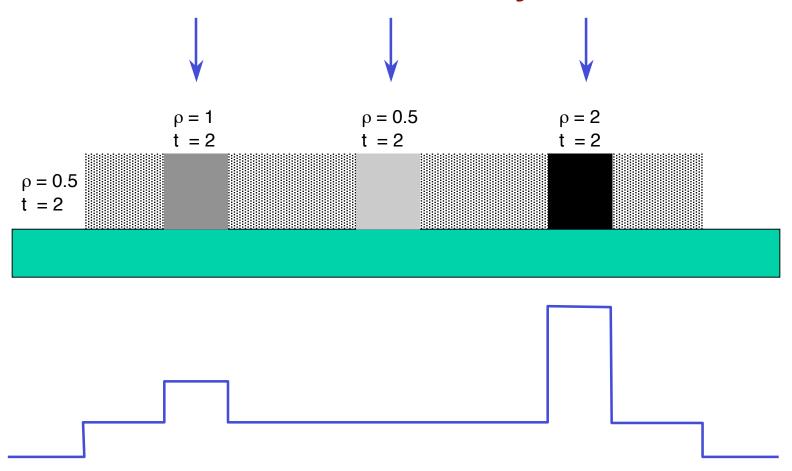
I.C.1 Electron Scattering



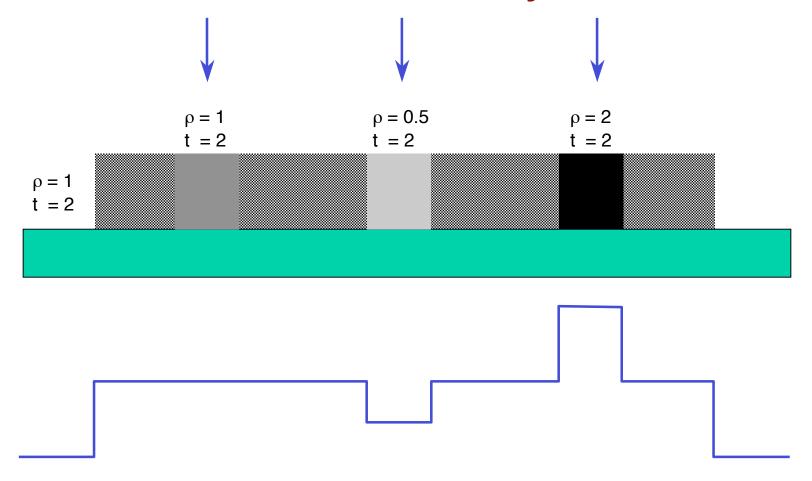
I.C.1 Electron Scattering



I.C.1 Electron Scattering



I.C.1 Electron Scattering



I.C.1 Electron Scattering

- Biological specimens have low Inherent contrast because they are mainly comprised of C, N, O, H
- Weak contrast is a limiting problem in imaging biological specimens (or very thin specimens)
- Inherent contrast increased by preferential addition of materials of high atomic number (basis of many different specimen preparation procedures)

I.C.1 Electron Scattering "Physics" of Electron Scatter

Consider an e⁻ beam as it passes through a specimen:

 Path of the beam is affected mainly by electrostatic interactions with the atomic <u>nuclei</u> or <u>electrons</u> in the electron shells surrounding the nuclei

I.C.1 Electron Scattering "Physics" of Electron Scatter

Recall: Matter is mainly **empty space**

- Beam electron must pass very close to atomic nucleus or electron before it will be deflected (i.e. scattered)
- Electrons rarely scatter due to direct collisions with atomic nuclei and electrons

I.C.1 Electron Scattering "Physics" of Electron Scatter

Primary types of electron/specimen scatter:

Elastic Inelastic None

I.C.1 Electron Scattering

Elastic scatter: No energy loss (no change in velocity or λ)

Inelastic scatter: Some energy loss (~10-20 eV)

- Energy transferred to atomic shell electrons
- Main cause of radiation damage in biological specimens
- Velocity of imaging electrons decreases (λ increases)

No scatter: Beam electrons which pass outside the range of the electrostatic field of atomic nuclei and atomic electrons are not scattered

- For "thin" specimens, a large fraction of electrons are unscattered

I.C.1 Electron Scattering

Proportions of inelastic and elastic collisions depend on the accelerating voltage and the nature of the specimen

EXAMPLE:

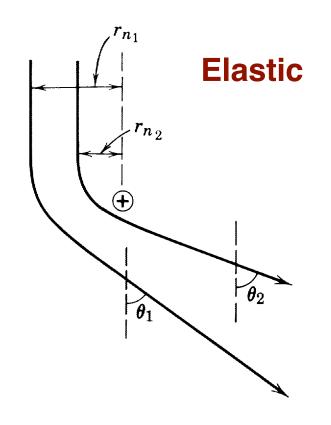
50 nm thick carbon film and 50kV electrons

34% unscattered

11% elastically scattered

55% inelastically scattered

I.C.1 Electron Scattering I.C.1.a Elastic Scattering



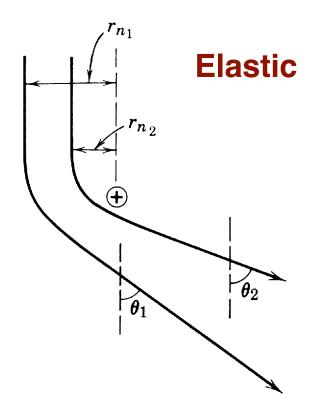
Electron trajectories in vicinity of a **nucleus**

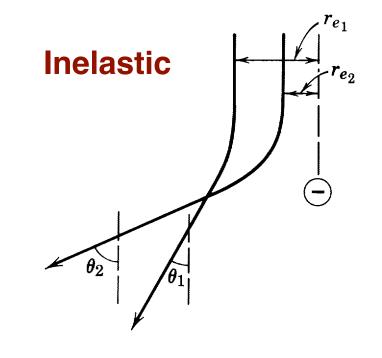
(From Slayter, Figs. 19-1, p. 423)

I.C.1 Electron Scattering

I.C.1.a Elastic Scattering

I.C.1.b Inelastic Scattering



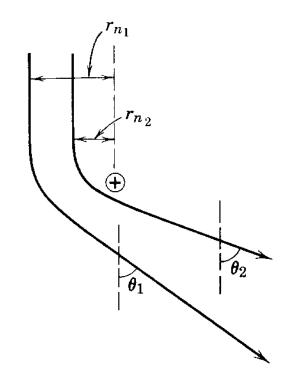


Electron trajectories in vicinity of a **nucleus**

Electron trajectories in vicinity of a 'stationary' electron

(From Slayter, Figs. 19-1, 19-2, p. 423)

I.C.1 Electron Scattering I.C.1.a Elastic Scattering

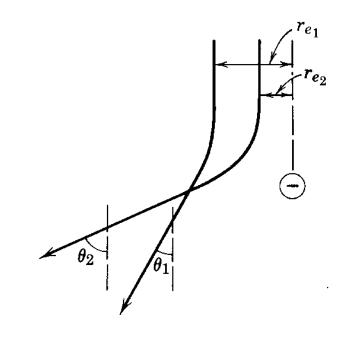


$$\theta_n = \frac{Ze}{Vr_n}$$

Elastic scattering of beam electrons by **electrostatic attraction** from the atomic **nucleus** leads to angular deflection, θ_n , of beam electrons

- Z = atomic number of specimen atom
- e = charge of an electron
- V = accelerating voltage of illumination beam
- r_n = distance of beam electron from stationary **atomic nucleus**

I.C.1 Electron Scattering I.C.1.b Inelastic Scattering

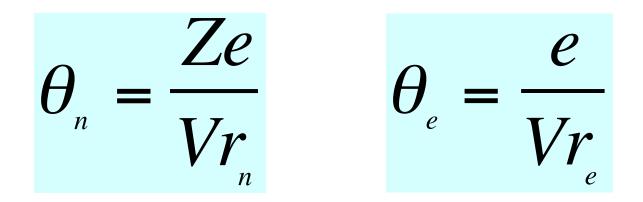


Inelastic scattering of beam electrons by **electrostatic repulsion** from the atomic **electrons** leads to angular deflection, θ_e , of beam electrons

- e = charge of an electron
- V = accelerating voltage of illumination beam
- $r_{\rm e}$ = distance of beam electron from **atomic electron**

I.C.1 Electron Scattering

Elastic vs. Inelastic



Nucleus has a higher scattering power than the atomic electron by a factor of *Z*, due to the greater concentration of charge in the nucleus

Consequence: electrons are generally scattered elastically to higher angles than those scattered inelastically (*i.e.* generally $\theta_n > \theta_e$)

I.C.1 Electron Scattering

I.C.1.b Inelastic Scattering

A few more facts...

- For electrostatic interactions between the beam electrons and the electrons surrounding the atomic nucleus, the deflected beam electrons undergo a loss of energy (*i.e.* shift to longer wavelength and lower velocity)
- Energy loss ~10-20 eV for 'thin' specimens (<100 nm)
- Beam electrons suffering ~10-20 eV energy loss are deflected through very small angles (~10⁻⁴ radians), thus nearly all of them pass through the objective aperture
- Generally only one scattering event as electron passes through a 'thin' specimen

I.C.1 Electron Scattering I.C.1.b Inelastic Scattering

And even some more facts...

- Energy loss due to inelastic collisions corresponds to fluctuations in the accelerating voltage of the order one part in 10⁴-10⁵
- Hence, change in λ produced by a single electron scattering event is relatively insignificant
- However, multiple scattering, which does occur in thick specimens, can be a serious source of chromatic aberration in TEM images

I.C.2 Amplitude/Phase Contrast

Contrast in electron images arises from both "amplitude" (scattering) and "phase" (interference) effects

AMPLITUDE CONTRAST:

Produced by **loss of amplitude** (*i.e.* electrons) from the imaging beam (particle nature of electrons)

PHASE CONTRAST:

Originates from **shifts in relative phases** of portions of imaging beam that combine and contribute to the image (wave nature of electrons)

I.C.2 Amplitude/Phase Contrast Scattering vs. Interference Contrast

Terms "amplitude" and "phase" misleading

More appropriate: scattering (or aperture) and interference contrast

However, many EM texts and articles often use terms "amplitude" and "phase" contrast, so **BEWARE of the distinction** I.C.2 Amplitude/Phase Contrast

Scattering vs. Interference Contrast

SCATTERING CONTRAST

 Primary source of electron contrast for most biological specimens prepared for TEM imaging by "conventional" methods (*i.e.* stained or shadowed with heavy atoms and hence of large mass thickness)

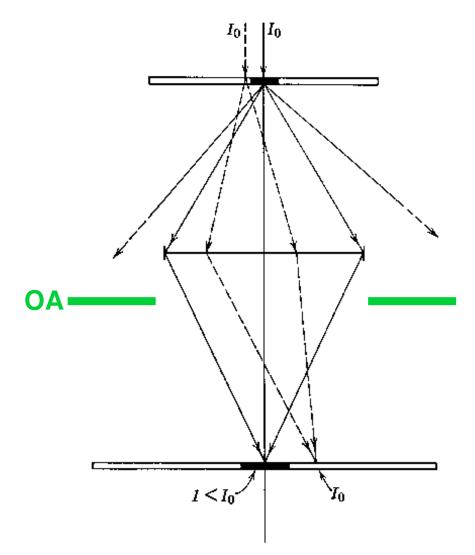
INTERFERENCE CONTRAST

- Arises from two factors:

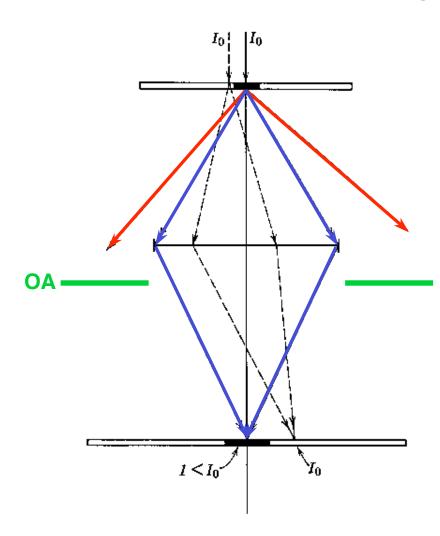
Defocusing the objective lens

Spherical aberration in the objective lens

- Importance increases as limit of resolution in TEM is approached and for small / thin structures
- Dominant source of contrast for very small objects of low atomic number



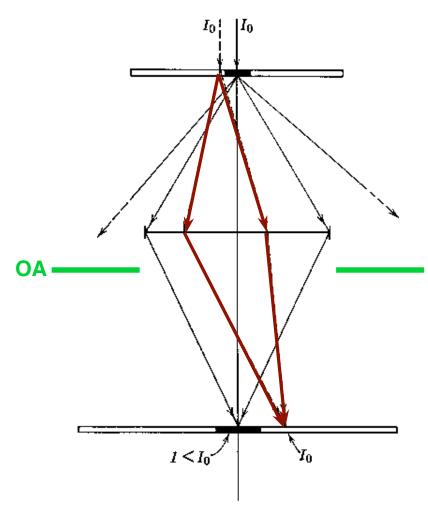
(From Slayter, Fig. 19-3, p. 427)



Electron opaque object points produce appreciable scattering of beam electrons through relatively large angles

These e⁻ are **excluded from** (*i.e.* fall outside) **the lens aperture**

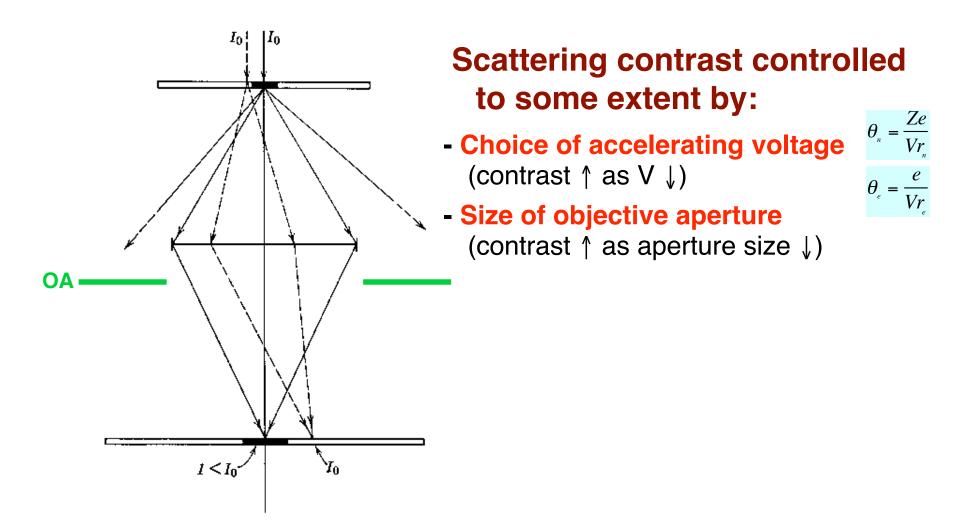
Intensity in these image points is correspondingly low



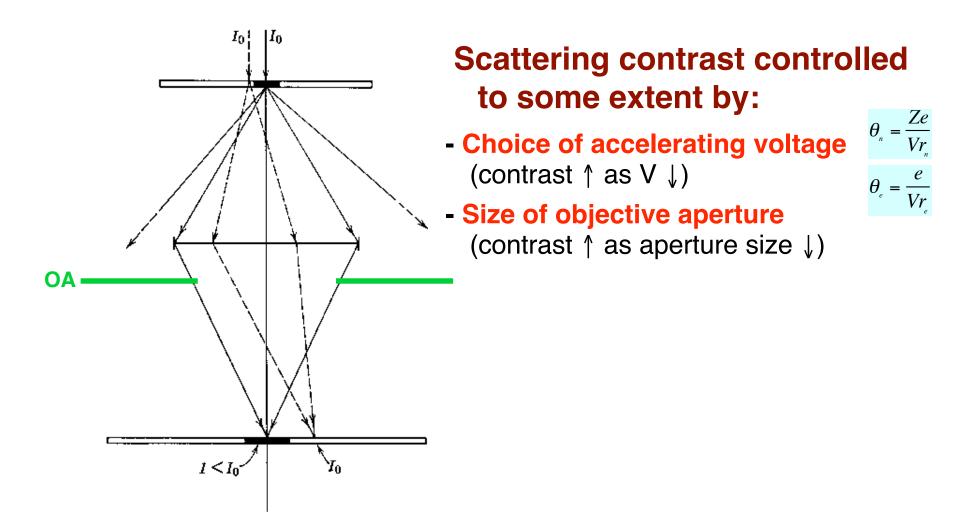
Conversely:

Electron transparent regions in the object (lower average atomic number and/or mass thickness) produce little scattering beyond the lens aperture

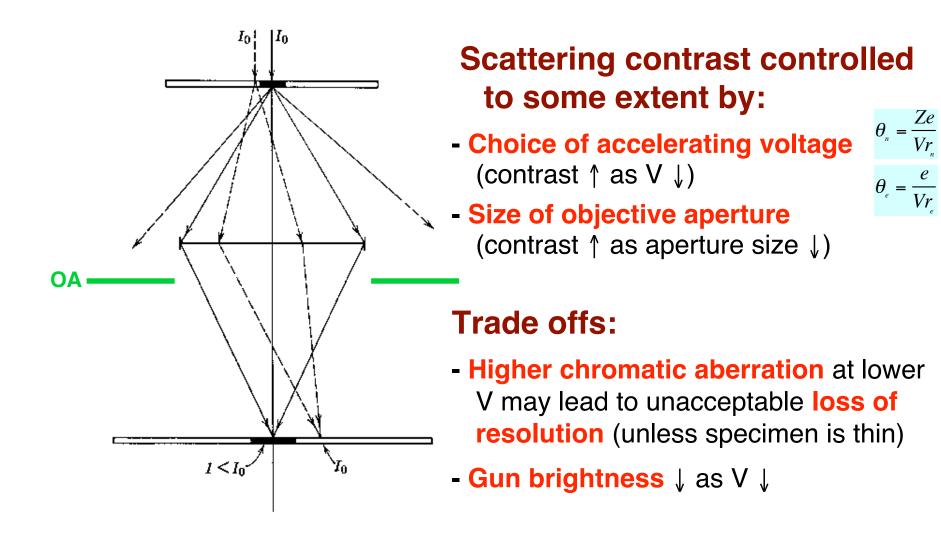
Intensity of these image points is correspondingly high



⁽From Slayter, Fig. 19-3, p. 427)

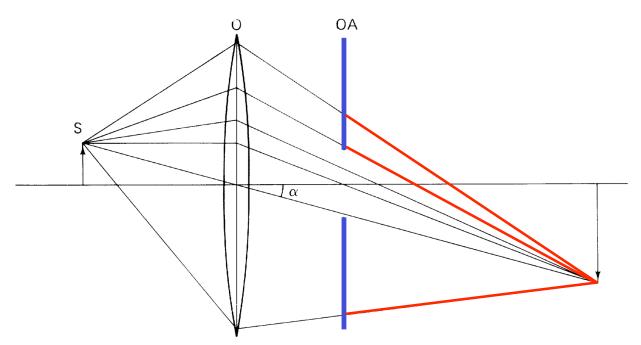


⁽From Slayter, Fig. 19-3, p. 427)



Objective Aperture Affects Scattering Contrast

- Objective aperture at **back focal plane** of objective lens



Objective Aperture Affects Scattering Contrast

- Objective aperture at **back focal plane** of objective lens
- As aperture size is **reduced**, more scattered electrons are stopped and "amplitude" (or aperture) **contrast improves**
- However, apertures too small (<20 μm) lead to loss of resolution due to diffraction effects (point in object leads to larger Airy disk image)

Objective Aperture Affects Scattering Contrast

Practical problems with small objective apertures:

- More **difficult to keep aligned** on the optical axis in the back focal plane of the objective lens
- More susceptible to the effects of contamination (produces lens asymmetry and astigmatism, thereby reducing resolution)

I.C.2.b Interference (Phase) Contrast

Interference ("phase") contrast is generated when scattered and unscattered (i.e. diffracted and undiffracted) electron waves interfere

This produces **differences in intensity** at the electron image

Recall:

- Electrons scattered through large angles (outside lens aperture) give rise to **scattering** ("amplitude") contrast
- <u>Ideally</u>, all other scattered electrons are focused by the lens at the corresponding image points, at which they arrive in phase

I.C.2 Amplitude/Phase Contrast I.C.2.b Interference (Phase) Contrast

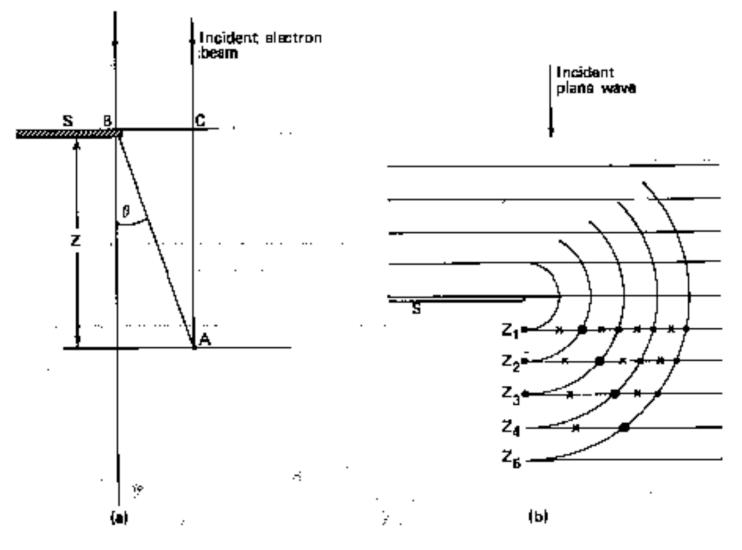
Interference contrast arises from phase differences and interference between scattered and unscattered rays in different parts of the image

Defocusing of objective lens:

- Causes path lengths of scattered rays to change more than for the unscattered rays
- Enhances contrast due to interference effects

Contrast due to phase differences are important for thin objects and when working near the resolution limit

I.C.2.b Interference (Phase) Contrast

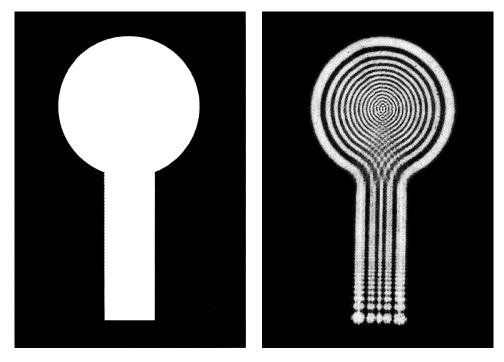


(From Agar, Fig. 3.8, p. 97)

I.C.2.b Interference (Phase) Contrast

Defocus or **phase contrast** appears as **Fresnel fringes** in the specimen

Fringes especially noticeable wherever there are sharp changes in mass thickness



I.C.2 Amplitude/Phase Contrast I.C.2.b Interference (Phase) Contrast

Fresnel fringes **disappear** at "exact" ("near" or "true") focus because phase differences are at a minimum

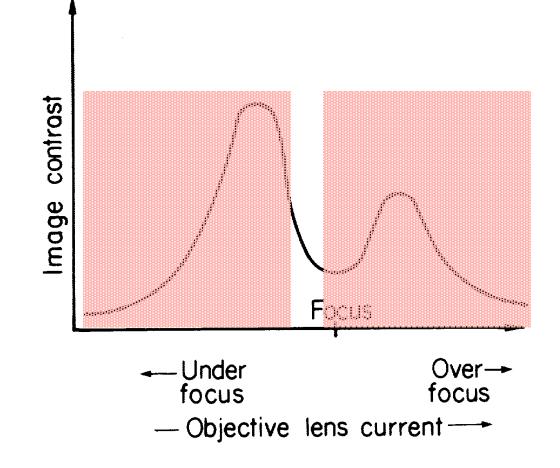
Practical tip:

Common practice to **defocus** (underfocus) **slightly** to image interference contrast

At slight defocus, resolution is not significantly reduced

I.C.2.b Interference (Phase) Contrast

Variation of Image Contrast with Objective Lens Focus



(From Meek, 2nd ed., Fig. 5.3, p.100)

I.C.3 Phase Contrast Transfer Function

Unfortunately, electron images do **not** give a **direct or completely faithful** rendering of the specimen density distribution

- Relationship between image and specimen is described by the contrast transfer function (CTF) which is characteristic of:

Particular microscope used Specimen Conditions of imaging

- Microscope CTF arises from the objective lens focal setting and from the spherical aberration present in all electromagnetic lenses
- CTF varies with the **defocus** and **accelerating voltage** according to a formula that includes both phase and amplitude contrast components

I.C.3 Phase Contrast Transfer Function

Dependence of CTF on **resolution**, **wavelength**, **defocus** and **spherical aberration** is given by:

$$CTF(v) = -\left\{ \left(1 - F_{amp}^{2}\right)^{\frac{1}{2}} \bullet \sin(\chi(v)) + F_{amp} \bullet \cos(\chi(v)) \right\}$$

$$\chi(\nu) = \pi \lambda \nu^2 \left(\Delta f - 0.5 C_s \lambda^2 \nu^2 \right)$$

v = spatial frequency (in Å⁻¹)

 F_{amp} = fraction of amplitude contrast

- λ = electron wavelength (in Å), where $\lambda = 12.3/\sqrt{V + 0.000000978 \cdot V^2}$ (= 0.037, 0.025, and 0.020Å for 100, 200, and 300 keV electrons, respectively)
- V = voltage (in volts)
- Δf = underfocus (in Å)
- C_s = spherical aberration of objective lens of microscope (in Å)

0.25 nm 0.5 0.4 0.3 5.0 d 1.0 +100% (a) Contrast $\Delta f = 0$ nm 0 4 $\Lambda = \frac{1}{d}$ 3 -100%0.25 nm 5.0 0,5 0.4 0.3 1.0 d +100% (b)Contrast $\Lambda f = -78 \text{ nm}$ 2 0 4 Λ -100% 0.5 0.4 0.3 0.25 nm 5.0 1.0 d +100% (c) $\Delta f = -234 \text{ nm}$ Contrast 0 2 3 IΛ -100%

I.C.3 Phase Contrast Transfer Function

Plot of phase contrast as a function of structure size. (a) Objective lens in focus. (b) Objective lens 78 nm underfocus. (c) Objective lens 234 nm underfocus

(Agar, p. 282)

I.C.3 Phase Contrast Transfer Function

FEAR NOT!!!

Though the importance of the CTF is unquestioned if one wishes to fully understand image formation in a TEM, a full discussion of the CTF is beyond the scope of an introductory course.

For **BIO595R**, you are **NOT** required to understand the CTF in any detail (and won't be quizzed on it!)

For those *fearless* people who enjoy the challenge, the full flavored nature of the CTF will be dissected in more detail in BIO595W ... and you will learn how images can be manipulated to reduce CTF effects and get a more accurate view of specimen features I.C.5 Other Methods for Enhancing Contrast

- Directly **increase specimen contrast** using various preparation procedures (*i.e.* staining, shadowing, etc.)

- Use longer exposure time for recording the photographic image

To be discussed in future lectures

End of Sec.I.C